

In the Specification:

Please AMEND the specification as follows:

At Page 10, lines 10-17:

A1
The transparent conductive film 39 and the common electrode 35 below the transparent conductive film 39 are electrically connected with each other through a contact hole 41 or by a laser welding 42. Since the transparent conductive film 39 has a pattern extended to the data electrode 37, the distance between the common electrode 35 and the data electrode 37 is narrowed by as much as the portion of the transparent conductive film 39 extended to the data electrode 37.

At Page 11, lines 1-6:

A2
The transparent conductive film 39 is formed on the passivation film 38 over the respective common electrodes 35 and extends toward adjacent data electrode 37. The transparent conductive film 39 and the common electrode 35 below the transparent conductive film 39 have an electrically connected structure, for example, through contact hole 41 or by laser welding 42.